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**Theoretical study on the influence of a secondary metal on the Cu(110) surface
with the presence of H₂O for methanol decomposition**

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Abstract: Density functional theory calculations with the continuum solvation slab model are performed to investigate the effect of metal dopants on the Cu(110) surface with the presence of H₂O for the methanol decomposition. The sequential dehydrogenation of methanol (CH₃OH→CH₃O→CH₂O→CHO→CO) is studied in present work. The results show that the introduction of different metals (Pt, Pd, Ni, Mn) on the H₂O/Cu(110) surface notably influence on the adsorption configurations and adsorption energies of all adsorbates, and remarkably affect the reaction energies and activation energies of the elementary steps. The Pt, Pd and Ni doped H₂O/Cu(110) surface are able to promote the hydrogen production from methanol decomposition, but Mn doped H₂O/Cu(110) surface is unfavorable for the reaction. The activity of methanol decomposition decreases in the follow: Pd-H₂O/Cu(110) > Pt-H₂O/Cu(110) > Ni-H₂O/Cu(110) > H₂O/Cu(110) > Mn-H₂O/Cu(110). Finally, the Brønsted-Evans-Polanyi plot for the main methanol dissociation steps on the metal doped and un-doped H₂O/Cu(110) surfaces are identified, and a linear relationship between the reaction energies and transition state energies is obtained.

Keywords: DFT; methanol decomposition; metal dopants; H₂O/Cu(110); BEP

1. Introduction

Nowadays, the worldwide energy consumption is still mainly on fossil fuels¹, but the excessive consumption of fossil fuels has caused climate change^{2,3} due to a huge amount of greenhouse gas emissions, that damaged our planet's ecosystem to some extent⁴. In order to meet the world's energy demand and improve the adverse environmental conditions, there is an urgency to explore alternative and environmentally-friendly energy resources. As an ideal fuel, more recently, hydrogen energy is receiving more and more attention because water is the sole by-product⁵. However, the intrinsic physical properties of hydrogen^{6,7} make it not an ideal energy media. Methanol can be used as a material for the storage of hydrogen⁸⁻¹¹, owing to the high energy density and H/C ratio, the absence of C-C bond, abundant and low-cost source as well as safer and more convenient to a long distance transportation.

Methanol decomposition ($\text{CH}_3\text{OH} \rightarrow 2\text{H}_2 + \text{CO}$ $\Delta H_{298\text{K}}^{\circ} = 90.7 \text{ KJ/mol}$) is an effective method for hydrogen production. Numerous efforts are devoted to understanding the mechanism of methanol decomposition on various metal surfaces, especially on transition metal catalysts¹²⁻²². The Cu based catalysts are widely used in hydrogen production from methanol due to the unique catalytic activity and selectivity¹⁵⁻¹⁷. However, during the reaction, the catalyst is easily suffering from the problem of thermal instability due to severe metal coking and sintering²³. To improve the catalytic performance and reduce the reaction temperature, substantial efforts are devoted to designing more effective catalysts. Bimetallic alloys are received extensively attention in heterogeneous

catalysis²⁴⁻³⁷. Due to their similar cell parameters and identical crystal structure, metallic Pt, Pd and Ni with Cu can form Pt-Cu, Pd-Cu and Ni-Cu binary alloys. Previous literature reported that the Pt-Cu alloy are used in hydrocarbon reforming reaction²⁵ and the Pd-Cu, Ni-Cu bimetallic alloy catalyst presenting superior behavior for the steam reforming of methanol^{33, 34}. In addition, the Cu-Mn spinel catalyst is used to the methanol steam reforming^{35, 36}. Up to now, no experimental and theoretical are reported to understand the hydrogen formation from methanol decomposition on metal (Pt, Pd, Ni, Mn) doped Cu based catalysts, and to further explore the influence of metal dopant on the reaction. Therefore, our work would be important to clarify the influence of a secondary metal for methanol decomposition, what's more, to explore new methanol decomposition catalysts.

To the best of our knowledge, many heterogeneous catalytical processes occurred in a solvent environment for the purpose of dissolving the reactants, and then influence on the reaction rate and products selectivity^{21, 38-40}. In the actual system for methanol decomposition, water or water vapor is almost never avoidable, and its influence on methanol dissociation needs to be deeply investigated. Unfortunately, few studies for heterogeneous catalysis which occurs on the solid/liquid interface are reported. Wang et al, Fang et al and Okamoto et al study the formic acid oxidation, methanol oxidation and the dehydrogenation of methanol on Pt(111) with the presence of water molecules⁴¹⁻⁴³. Their research showed that the water molecules significantly affect the adsorption energies and activation energies of the corresponding adsorbates and elementary steps. In this work, water molecules are

added onto the solid surface to simulate the behavior of methanol decomposition on the solid/liquid interface environment.

Therefore, in the present study, by using the density functional theory (DFT), the methanol decomposition on the metal (Pt, Pd, Ni, Mn) doped and un-doped H₂O/Cu surfaces are investigated to understand the bimetallic effect on the reaction. To further elucidate the Kinetic-Thermodynamic relationships, Brønsted-Evans-Polanyi (BEP) plot is also carried out. The results are expected to reveal the mechanism of methanol decomposition on the metal doped Cu catalysts with the presence of water molecules. Furthermore, the calculation results may be useful for designing new catalytic materials for methanol decomposition reaction.

2. Computational models and methods

2.1. Surface model

For methanol decomposition, the real copper catalyst is modeled by the Cu(110) surface, and explicit four water molecules are added onto the Cu(110) surface as the first solvation shell to model the solvation environment.

The Cu(110) surface is cleaved from the face-centered cubic (fcc) crystal structure, and the lattice parameter of Cu is 3.615 Å, which is in agreement with the experimental values^{44,45}. From the optimized bulk structure, the Cu(110) surface is modeled using a four atomic layer slabs with a periodic p(3 × 3) unit cell, and 9 atoms at each layer. Meanwhile, a 15 Å thick vacuum gap is employed to separate the periodic images of the slab. In all calculations, the top two layers and adsorbates are allowed fully relaxed and the bottom two slab layers are fixed in their bulk position.

One surface Cu atom is substituted by a dopant (Pt, Pd, Ni, Mn) atom, and the corresponding dopant coverage is 1/9 ML. As shown in Fig.1(a) and (b), the structure of M-H₂O/Cu(110) (M: Pt, Pd, Ni, Mn) and un-doped H₂O/Cu(110) surfaces are used for the present calculation.

2.2. Calculation methods

The Kohn-Sham DFT calculation is performed using the Vienna ab initio simulation package (VASP)^{46, 47} with the projector-augmented wave (PAW) pseudopotentials⁴⁸. The generalized gradient approximation (GGA) with the Perdew, Burke and Ernzerhof (PBE) functional is used to treat the exchange-correlation energy⁴⁸⁻⁵⁰. The kinetic energy cutoff is 400 eV. A $3 \times 3 \times 1$ Monkhorst-Pack k-point mesh with Monkhorst-Paxton smearing of 0.1 eV is sampled to the Brillouin zone⁵¹. The transition states (TS) and the minimum energy paths (MEP) are studied using the climbing-image nudged elastic band (CI-NEB) method⁵² combined with the dimer method⁵³. The TS is identified with imaginary frequencies through the vibrational analysis. The geometries structure is deemed converged until the forces of all relax atoms are less than 0.03 eV/Å, and the convergence of energy is set to 1×10^{-5} eV. The molecules in the gas phase are calculated using a $15 \times 15 \times 15 \text{ \AA}^3$ cubic unit cell.

The adsorption energy (E_{ads}) is defined as:

$$E_{\text{ads}} = E_{(\text{adsorbate}+4\text{H}_2\text{O})/\text{slab}} - E_{4\text{H}_2\text{O}/\text{slab}} - E_{\text{adsorbate}}$$

$E_{(\text{adsorbate}+4\text{H}_2\text{O})/\text{slab}}$ is the total energy of the adsorbate on the metal (Pt, Pd, Ni, Mn) doped or un-doped H₂O/Cu(110) surface. $E_{4\text{H}_2\text{O}/\text{slab}}$ is the energy of the metal (Pt, Pd, Ni, Mn) doped or un-doped H₂O/Cu(110) surface. $E_{\text{adsorbate}}$ is the energy of the

adsorbate molecule in vacuum situation. Obviously, a negative E_{ads} value represents exothermic adsorption, and more negative values indicates the strong interaction between the adsorbates with the $\text{H}_2\text{O}/\text{Cu}(110)$ surface.

3. Results and discussion

3.1. Reaction intermediates

The most stable adsorption configurations of the reaction intermediates on the metal (Pt, Pd, Ni, Mn) doped and un-doped $\text{H}_2\text{O}/\text{Cu}(110)$ surfaces, which involves CH_3OH , CH_3O , CH_2O , CHO and CO , are shown in Fig.2. In addition, we have to mention that the reaction intermediates with the presence of water molecules can form hydrogen bond⁴², which may facilitate the adsorption.

3.2. Reaction Mechanism

To our best knowledge, CH_3OH decomposition involves a series of elementary steps on the Cu catalysts^{12, 13, 54-56}. According to the previous DFT reported^{12, 13, 55-57}, the C-H scission of methanol or intermediates during methanol decomposition is easier than that of C-O scission, and the sequential dehydrogenation steps of CH_3OH is the main route for CH_3OH decomposition, as follows: $\text{CH}_3\text{OH} \rightarrow \text{CH}_3\text{O} \rightarrow \text{CH}_2\text{O} \rightarrow \text{CHO} \rightarrow \text{CO}$. Therefore, in the following discussion, we will concentrate on the reactions between the main dehydrogenation products on the metal (Pt, Pd, Ni, Mn) doped $\text{H}_2\text{O}/\text{Cu}(110)$ surfaces, and the results are compared with those obtained on the un-doped $\text{H}_2\text{O}/\text{Cu}(110)$ surface. In all calculations, we use IS, TS and FS to represent the initial state, the transition state and the final state, respectively.

3.2.1 Pt- $\text{H}_2\text{O}/\text{Cu}(110)$

For the methanol decomposition on the Pt doped H₂O/Cu(110) surface, the potential energy diagram with the optimal pathway is shown in Fig.3. The initial step of the reaction (CH₃OH→CH₃O+H) starts from the adsorbed CH₃OH, where the CH₃OH adsorbs on Pt through O with an adsorption energy of -38.58 KJ/mol. The dehydrogenation step through TS1 needs to overcome a barrier of 43.40 KJ/mol with exothermicity of -27.00 KJ/mol. The formation of CH₂OH via C-H bond scission from CH₃OH has an activation energy of 188.06 KJ/mol, which is higher than that of the CH₃O formation (43.40 KJ/mol), (see Fig S1 in the supporting information). The result indicates that the CH₃O formation from CH₃OH is easily to happen. The dehydrogenation of CH₃O is the next step and the CH₃O adsorbs on the Pt-Cu site with an adsorption energy of -277.75 KJ/mol. The CH₂O and H are generated during the CH₃O dissociation through TS2. The reaction (CH₃O → CH₂O+H) has an activation energy of 49.18 KJ/mol with endothermicity of 15.43 KJ/mol. Immediately following, the further dehydrogenation of CH₂O to CHO, which is labeled as CH₂O→CHO+H. After optimization, the CH₂O adsorbs on the Pt-Cu site with C and O bind to Pt and Cu, respectively. The corresponding adsorption energy is -85.83 KJ/mol. After the TS3, the CHO and H are produced, and the reaction is exothermicity of -30.86 KJ/mol with an activation energy of 50.15 KJ/mol. The adsorption energy of CHO is -286.43 KJ/mol, where the CHO adsorbs on Pt through C. Subsequently, the dehydrogenation of CHO to CO (CHO→CO+H) through TS4 is exothermic by -72.33 KJ/mol and needs to overcome a barrier of 60.76 KJ/mol.

3.2.2 Pd-H₂O/Cu(110)

On the Pd doped H₂O/Cu(110) surface, the potential energy diagram of the main route for CH₃OH decomposition is given in Fig.4. The reaction initiates by the dehydrogenation of the adsorbed CH₃OH to generate CH₃O and H through TS5. The stable adsorption structure of CH₃OH adsorbs on Pd via O with an adsorption energy of -50.15 KJ/mol. This reaction is endothermic of 6.75 KJ/mol with an activation energy of 19.29 KJ/mol. We also note that the CH₂OH formation needs to overcome a high barrier of 189.99 KJ/mol, which is higher than that of the CH₃O formation (19.29 KJ/mol). Similar to that of on the Pt doped H₂O/Cu(110) surface, the CH₂OH formation is unlikely to occur (the corresponding details are shown in Fig.S1 in the supporting information). Subsequently, the formed CH₃O further dehydrogenate to CH₂O via TS6, which has an activation energy of 41.47 KJ/mol with endothermicity of 12.54 KJ/mol. In this step, CH₃O strongly binds to the Pd-Cu site with an adsorption energy of -280.64 KJ/mol. After the TS6, the formed CH₂O adsorbs on the Pd-Cu site through C and O bind to Pd and Cu, respectively. The corresponding adsorption energy is -82.94 KJ/mol. The next step is the CHO formation through TS7. The dehydrogenation of CH₂O is energetically neutral with exothermic by -0.96 KJ/mol, and the activation energy is 39.54 KJ/mol. The final step is the CO production from the CHO→CO+H reaction via TS8. After optimization, The CHO adsorbs on Pt through C with an adsorption energy of -256.53 KJ/mol, and the formed CO binds to Pt through C. The calculated activation energy for this step is 57.86 KJ/mol, and the reaction is exothermic by -71.37 KJ/mol.

3.2.3 Ni-H₂O/Cu(110)

In the case of CH₃OH decomposition on the Ni doped H₂O/Cu(110) surface, the potential energy diagram of the main steps is presented in Fig.5. Similar to the case of CH₃OH dissociation on the Pt and Pd doped H₂O/Cu(110) surface, there are two possible paths for the initial CH₃OH dehydrogenation: O-H and C-H bond scission routes. For the reaction of CH₃OH→CH₃O+H, after optimization, the CH₃OH adsorbs on Ni through O with an adsorption energy of -74.26 KJ/mol, and the CH₃O and H are generated through TS9. This step is moderately uphill, and needs to overcome a barrier of 92.58 KJ/mol with exothermicity of -44.36 KJ/mol. The formation of CH₂OH requires an activation energy of 169.73 KJ/mol, which is higher than that of the CH₃O formation (92.58 KJ/mol), (see Fig.S1). Therefore, the CH₃O formation is easy to occur. Subsequently, the formed CH₃O further dehydrogenate to CH₂O through TS10. In this step, the adsorbed CH₃O binds to Ni with an adsorption energy of -338.50 KJ/mol. The activation energy and reaction energy are 103.19 and 28.93 KJ/mol, respectively. The next step is CH₂O dissociation through TS11. In this process, the CH₂O adsorbs on Ni through both C and O with an adsorption energy of -130.19 KJ/mol. The reaction of the CHO and H production from CH₂O species is calculated to be exothermic by -23.15 KJ/mol with an activation energy of 62.69 KJ/mol. The last step for the stepwise dehydrogenation of CH₃OH on the Ni doped H₂O/Cu(110) surface is the CHO dissociation to CO via TS12, which is labeled as CHO→CO+H. The most stable adsorption configuration of CHO binds to Ni through C, and the corresponding adsorption energy is -308.61 KJ/mol. This step is exothermic by -72.33 KJ/mol, and needs to overcome a barrier of 27.00 KJ/mol.

3.2.4 Mn-H₂O/Cu(110)

On the Mn doped H₂O/Cu(110) surface, the reaction coordinates for CH₃OH decomposition with the optimal pathway are depicted in Fig.6. Initially, CH₃OH adsorbs on Mn via O with an adsorption energy of -118.62 KJ/mol. The initial step of CH₃OH→CH₃O+H via TS13 has an activation energy of 26.04 KJ/mol, and the reaction energy is -91.62 KJ/mol. As another possible pathway, the CH₂OH formation is unlikely due to the high activation energy of 162.02 KJ/mol (see Fig.S1 in the supporting information). The following step is the dehydrogenation of CH₃O to CH₂O through TS14 with an activation energy of 123.44 KJ/mol, and the reaction is energetically neutral with endothermicity of 0.96 KJ/mol. In this step, the adsorbed CH₃O binds to Mn through O with an adsorption energy of -455.20 KJ/mol. Subsequently, the formed CH₂O adsorbs on the Mn-Cu site with O and C anchoring to Mn and Cu, respectively. In addition, the adsorption energy of CH₂O is -270.03 KJ/mol. Subsequently, the CH₂O is prone to further dehydrogenation. After the TS15, the CHO and H are generated. This step is endothermic by 60.76 KJ/mol with an activation energy of 93.55 KJ/mol. Finally, the CO is formed from the CHO dehydrogenation through TS16. In this step, the CHO adsorbs on Mn via C with an adsorption energy of -370.33 KJ/mol, and the corresponding activation energy and reaction energy are 53.04 KJ/mol and -81.01 KJ/mol, respectively.

3.2.5 Un-doped H₂O/Cu(110)

In order to compare with the results of on the metal (Pt, Pd, Ni, Mn) doped H₂O/Cu(110) surfaces, we also investigate the CH₃OH decomposition on the

un-doped H₂O/Cu(110) surface. The potential energy diagram with the optimal pathway is shown in Fig.7. Based on the energetic data from our calculation, CH₃OH adsorbs on the top site through O with an adsorption energy of -47.26 KJ/mol, and the dissociation of CH₃OH via the O-H bond scission give rise to the chemisorbed CH₃O and H through TS17. The reaction CH₃OH→CH₃O+H is exothermic by -14.47 KJ/mol with an activation energy of 41.47 KJ/mol. By contrast, the CH₂OH formation needs to overcome a barrier of 167.81 KJ/mol, which is higher than that of the CH₃O formation (41.47 KJ/mol), (see Fig.S1). Therefore, the CH₃O formation is easy to happen. The CH₃O intermediate leads to CH₂O through TS18. In this step, the CH₃O binds to the short-bridge site through O with an adsorption energy of -307.64 KJ/mol. The calculated activation energy is 112.83 KJ/mol, and the reaction energy is 91.62 KJ/mol. Subsequently, the CH₂O dehydrogenate to CHO via TS19. This step starts from the adsorbed CH₂O, where binds to the hollow site with C and O anchoring to the Cu, and the corresponding adsorption energy is -58.83 KJ/mol. The activation energy is 91.62 KJ/mol with endothermic by 19.29 KJ/mol. Finally, the adsorbed CHO coordinates to the top site via C with an adsorption energy of -224.71 KJ/mol, and CO is produced through TS20. The reaction CHO→CO+H requires an activation energy of 11.57 KJ/mol with exothermicity of -44.36 KJ/mol.

3.3. General Discussion

In this section, a detailed comparison of CH₃OH decomposition on the metal (Pt, Pd, Ni, Mn) doped and un-doped H₂O/Cu(110) surfaces are presented. Obviously, the introduction of metal (Pt, Pd, Ni, Mn) affects the adsorption energies of all the

adsorbates. On the un-doped H₂O/Cu(110) surface, CH₂O is easy to desorb instead of being further dehydrogenated due to the lower desorption energy than the activation energy of CHO formation (58.83 vs 91.62 KJ/mol), which is in consistency with the experimental observation^{58,59}. Interestingly, the introduction of metal (Pt, Pd, Ni, Mn) into H₂O/Cu(110) surface increase the bonding strength of CH₂O, which effectively hinders the CH₂O desorption (85.83 vs 50.15 KJ/mol, 82.94 vs 39.54 KJ/mol, 130.19 vs 62.69 KJ/mol, 270.03 vs 93.55 KJ/mol). Comparing with the results of CH₃OH dehydrogenation on the un-doped H₂O/Cu(110) surface, it is easy to find that the doping metal (Pt, Pd, Ni, Mn) on the H₂O/Cu(110) surface remarkably affect the reaction energies and activation energies of the main steps during CH₃OH decomposition processes.

For un-doped H₂O/Cu(110), the sequential dehydrogenation of CH₃OH to form CH₃O (41.47 KJ/mol activation energy), CH₂O (112.83 KJ/mol activation energy), CHO (91.62 KJ/mol activation energy) and CO (11.57 KJ/mol activation energy) is calculated. The rate-limiting step is the CH₃O dehydrogenation to CH₂O with a high activation energy (112.83 KJ/mol), which is in consistency with the previous DFT reported^{12,13}. For the Pt and Pd metals doped H₂O/Cu(110), as shown in Fig.3 and Fig.4, the activation energies for CH₃O formation are 43.40 and 19.29 KJ/mol, respectively, and both reactions are easy to occur. More importantly, compared to that of on the un-doped H₂O/Cu(110) surface, the activation energies for CH₃O dehydrogenation are significantly reduced (49.18 vs 112.83 KJ/mol, 41.47 vs 112.83 KJ/mol). The CHO formation is relatively easy on both Pt and Pd metals doped

H₂O/Cu(110) with the activation energies of 50.15 and 39.54 KJ/mol, respectively. The rate-limiting step is the CO formation from CHO dissociation, and the corresponding activation energies are 60.76 and 57.86 KJ/mol, respectively. Overall, the Pt and Pd dopants are favorable for the hydrogen formation from CH₃OH decomposition. For the CH₃OH decomposition on the Ni-doped H₂O/Cu(110), the activation energy of CH₃O formation is 92.58 KJ/mol, which is significantly higher than that on the un-doped H₂O/Cu(110) surface (41.47 KJ/mol), indicating that Ni dopant hinder the O-H bond scission of CH₃OH to some extent. The CH₂O formation is the rate-limiting step with an activation energy of 103.19 KJ/mol, which is lower than that of the un-doped H₂O/Cu(110) surface (112.83 KJ/mol). Subsequently, the sequential dehydrogenation of CH₂O to form CHO (62.69 KJ/mol activation energy) and CO (27.00 KJ/mol activation energy) are easy to occur. Therefore, the hydrogen formation from CH₃OH decomposition is also facilitated by the Ni dopant, which is similar to the previous experimental observation ²⁶. For the Mn-doped H₂O/Cu(110), as shown in Fig.6, the activation energies of the successive dehydrogenation of CH₃OH (CH₃OH→CH₃O→CH₂O→CHO→CO) are 26.04, 123.44, 93.55 and 53.04 KJ/mol. The rate-limiting step is also the CH₂O formation with an activation energy of 123.44 KJ/mol, which is higher than that on the un-doped H₂O/Cu(110) surface (112.83 KJ/mol). From the perspective of kinetics, the Mn doped H₂O/Cu(110) surface is slightly unfavorable for the CH₃OH dehydrogenation.

In summary, the sequential dehydrogenation of CH₃OH (CH₃OH→CH₃O→CH₂O→CHO→CO) on the metal (Pt, Pd, Ni, Mn) doped and un-doped H₂O/Cu(110) are

calculated and compared. Among all the metals doped H₂O/Cu(110) surfaces, the catalytic activity sequence for CH₃OH dehydrogenation is as follows: Pd-H₂O/Cu(110) > Pt-H₂O/Cu(110) > Ni-H₂O/Cu(110) > H₂O/Cu(110) > Mn-H₂O/Cu(110). Therefore, the metal dopants on the H₂O/Cu(110) surface play a significant role in CH₃OH decomposition reaction.

3.3.1 Electronic properties

In order to further clarify the influence of the dopants to local electronic structure of catalyst, the corresponding total density of states (DOS) and partial density of states (PDOS) of metal (Pt, Pd, Ni, Mn) doped H₂O/Cu(110) and un-doped H₂O/Cu(110) are investigated. As shown in the supporting information of Fig.S2, from the DOS, the energy gap exist from -21.00 eV to -10.50 eV for all the metal doped and un-doped H₂O/Cu(110) catalysts. Meanwhile, it is easy to find that the large and prominent peaks in DOS calculation mainly drive from Cu-3d state contribution. The low peaks in DOS from -22.20 eV to -21.00 eV and -10.50 eV to -9.00 eV are mainly drive from O-2s and O-2p state contribution, respectively.

To our knowledge, the electron distribution difference between metal dopants and neighboring copper atoms may causes the local electronic structure distortion, and then, changing the chemical and physical properties of catalysts. As shown in Fig.8 (a-e), comparing the PDOS curves, we can find that there exist a significant orbitals hybridization between Pt, Pd and Cu due to a large orbitals overlap of Pt 5d, Pd 4d orbital with Cu 3d orbital, respectively. There have a relative small orbital overlap between Ni and Cu, indicating that a relatively weakly hybridization of Ni 3d orbital

and Cu 3d orbital. Therefore, the local electronic distribution is changed effectively, especially for Pt and Pd metal dopants. This change may facilitate the catalytic reaction. In addition, slight orbital overlap between Mn 3d and Cu 3d is observed, which may not have a positive influence on catalytic reaction.

3.3.2 Kinetic-Thermodynamic Relationships

The kinetic and thermodynamic relationship is put forward by Brønsted⁶⁰, Evans and Polanyi⁶¹(BEP), and the BEP relationship is reintroduced into the DFT framework by Neurock⁶² and Nørskov⁶³. Recently, BEP correlations are reported for the dissociation reactions, such as the diatomic molecules bond scission⁶³, the ethanol dissociation⁶⁴, the water-gas shift reaction⁶⁵⁻⁶⁷ and the methanol decomposition and reverse reaction⁵⁵. The BEP relationship is combined with linear scaling relations to estimate activation energy by the reaction energy changes of the elementary reaction on the corresponding catalytic processes without calculating the corresponding transition states, which saves computational cost to some extent.

Fig.9 shows the BEP plot for the CH₃OH dissociation steps associated with the main reaction route including O-H and C-H bond activation studied on the metal (Pt, Pd, Ni, Mn) doped and un-doped H₂O/Cu(110) surfaces. In this work, good BEP correlation means that the activation energies increase with the increase of reaction energies for the CH₃OH dehydrogenation elementary steps. In other word, the more the exothermic of the reaction is, the lower the corresponding activation energy will be. The slope of the identified BEP relationship are greater than 0.7, which means that surface decomposition reactions approach to product-like or late barrier.

4. Conclusions

In this paper, the periodic and self-consistent DFT calculations are performed to systematically investigate the effect of metal dopants on the H₂O/Cu(110) surface for CH₃OH decomposition reaction. The sequential dehydrogenation steps of CH₃OH (CH₃OH → CH₃O → CH₂O → CHO → CO) is studied. The result show that the introduction of metal (Pt, Pd, Ni, Mn) on the H₂O/Cu(110) surface notably influence the adsorption configurations and adsorption energies of all the adsorbates, and remarkably affect the reaction energies and activation energies of the elementary steps. The metal dopants are effectively hinder the by-product of CH₂O desorption. Overall, the Pt, Pd and Ni dopants are able to promote the hydrogen formation from CH₃OH decomposition, while Mn doped is unfavorable for the reaction. The CH₃OH decomposition catalytic activity is found to decrease in the sequence: Pd-H₂O/Cu(110) > Pt-H₂O/Cu(110) > Ni-H₂O/Cu(110) > H₂O/Cu(110) > Mn-H₂O/Cu(110).

On the basic of the main CH₃OH decomposition pathway, the Brønsted - Evans - Polanyi plot for the CH₃OH dehydrogenation steps on the metal (Pt, Pd, Ni, Mn) doped and un-doped H₂O/Cu(110) surfaces is identified, and a linear relationship between all reaction energies and transition state energies are presented. Finally, our study may be useful for the designing of novel Cu-based catalysis for CH₃OH decomposition on the liquid/solid interface.

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Figure caption

Fig.1 The top view surface configuration of the H₂O/Cu(110) surface: (a) metal (Pt, Pd, Ni, Mn) doped; (b) un-doped.

Fig.2 The configurations of the reaction intermediates involved in methanol decomposition on the metal (Pt, Pd, Ni, Mn) doped and un-doped H₂O/Cu(110) surfaces (The Cu, Pt, Pd, Ni, Mn, C, O and H atoms are shown in the brown, deep blue, dark green, wathet blue, purple, gray, red, and white balls, respectively).

Fig.3 Potential energy profile of the main route for CH₃OH decomposition on the Pt doped H₂O/Cu(110) surface.

Fig.4 Potential energy profile of the main route for CH₃OH decomposition on the Pd doped H₂O/Cu(110) surface.

Fig.5 Potential energy profile of the main route for CH₃OH decomposition on the metal Ni doped H₂O/Cu(110) surface.

Fig.6 Potential energy profile of the main route for CH₃OH decomposition on the Mn doped H₂O/Cu(110) surface.

Fig.7 Potential energy profile of the main route for CH₃OH decomposition on the un-doped H₂O/Cu(110) surface.

Fig.8. The partial density of states (PDOS) for metal (Pt, Pd, Ni, Mn) doped H₂O/Cu(110) (a, b, c and d) and un-doped H₂O/Cu(110) (e). The insets are the PDOS of the metal dopants and neighboring copper atom.

Fig.9. Brønsted-Evans-Polanyi plots of the calculated transition state energy (E-TS) versus final state energy (E-FS) for the main route of CH₃OH decomposition on the metal (Pt, Pd, Ni, Mn) doped and un-doped H₂O/Cu(110) surfaces. The reactant energy in vacuum as a reference to calculate the transition and final state energies of each elementary reaction.

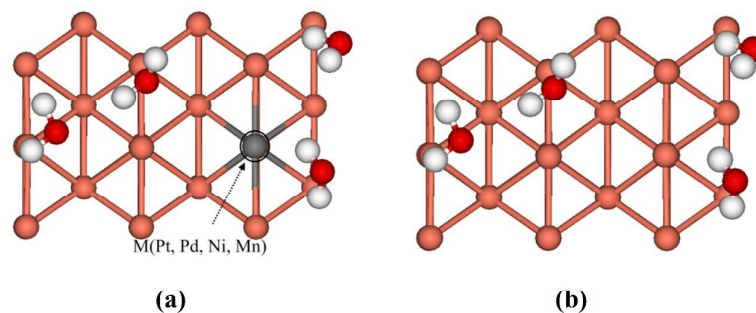
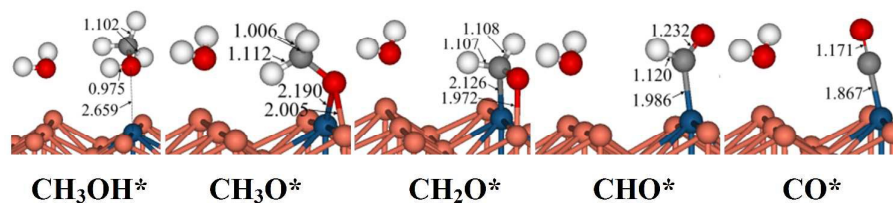
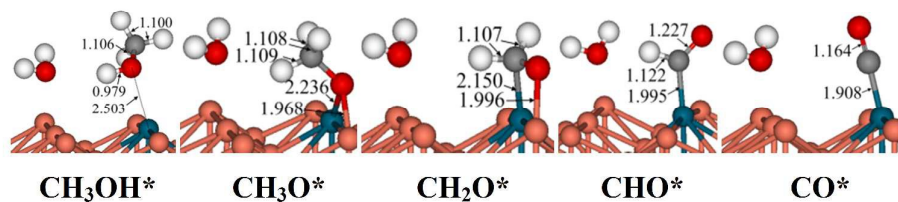


Fig.1 The top view surface configuration of the H₂O/Cu(110) surface: (a) metal (Pt, Pd, Ni, Mn) doped; (b) un-doped.

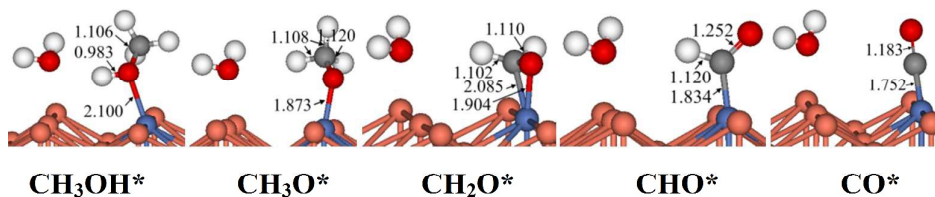
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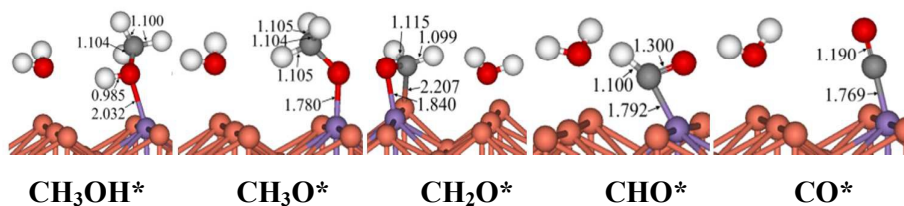
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(Ni-doped H₂O/Cu(110) surface)



(Mn-doped H₂O/Cu(110) surface)



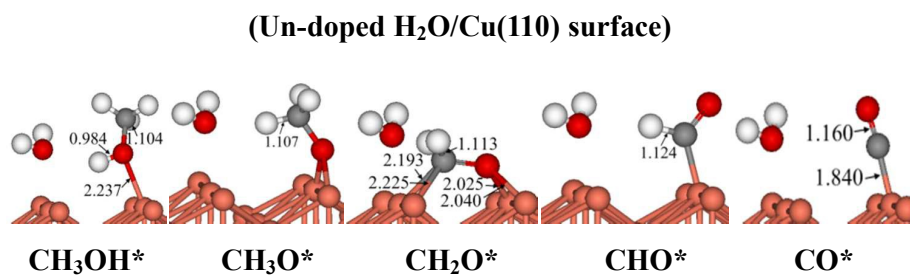


Fig.2 The configurations of the reaction intermediates involved in methanol decomposition on the metal (Pt, Pd, Ni, Mn) doped and un-doped H₂O/Cu(110) surfaces (The Cu, Pt, Pd, Ni, Mn, C, O and H atoms are shown in the brown, deep blue, dark green, wathet blue, purple, gray, red, and white balls, respectively).

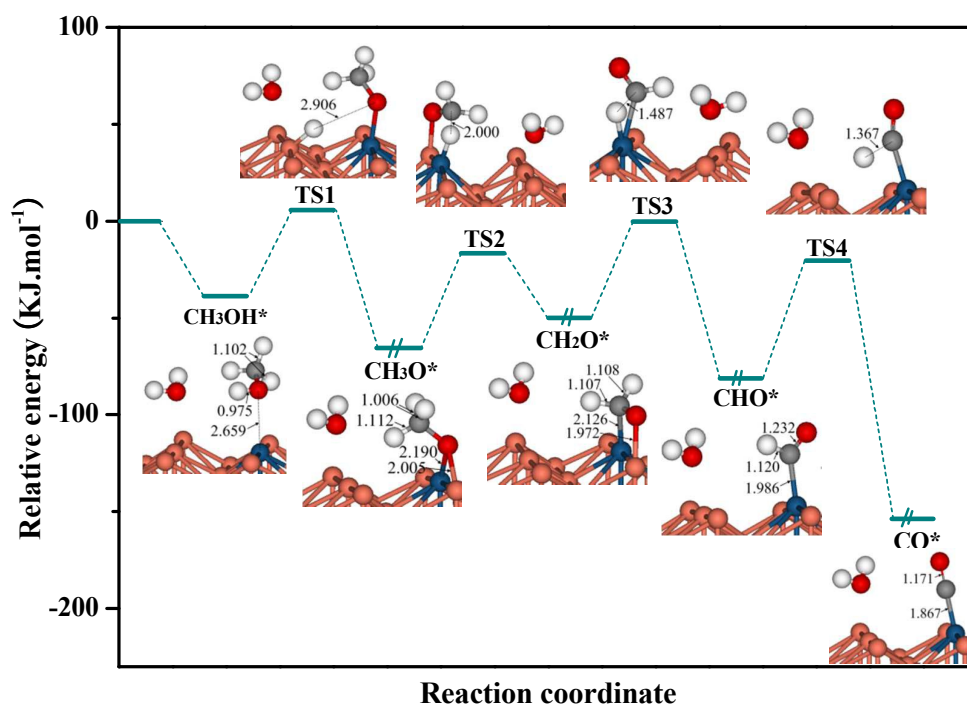


Fig.3 Potential energy profile of the main route for CH₃OH decomposition on the Pt doped H₂O/Cu(110) surface.

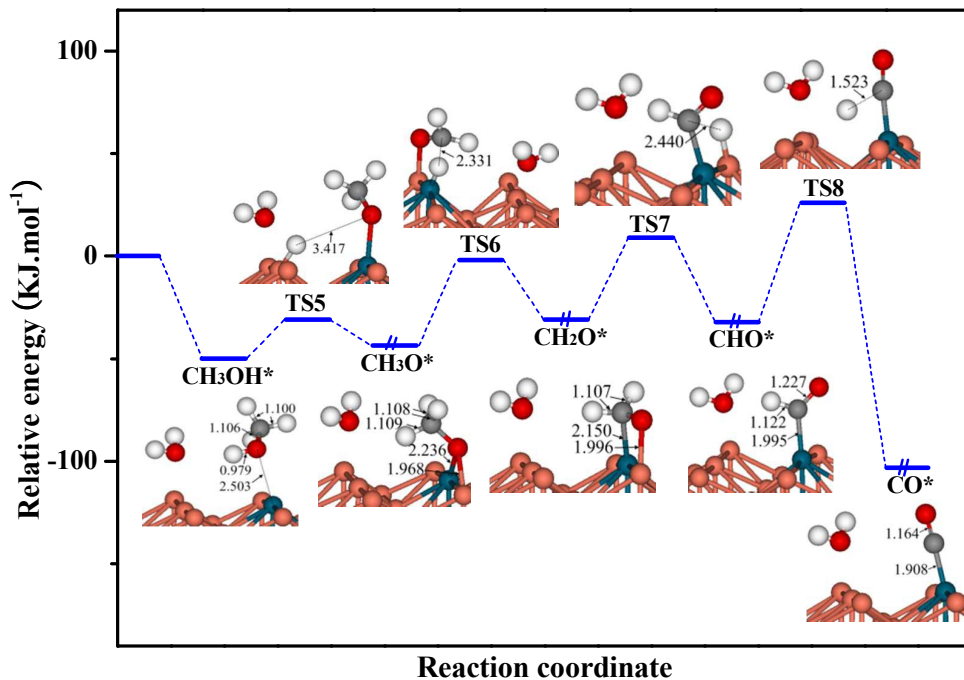


Fig.4 Potential energy profile of the main route for CH₃OH decomposition on the Pd doped H₂O/Cu(110) surface.

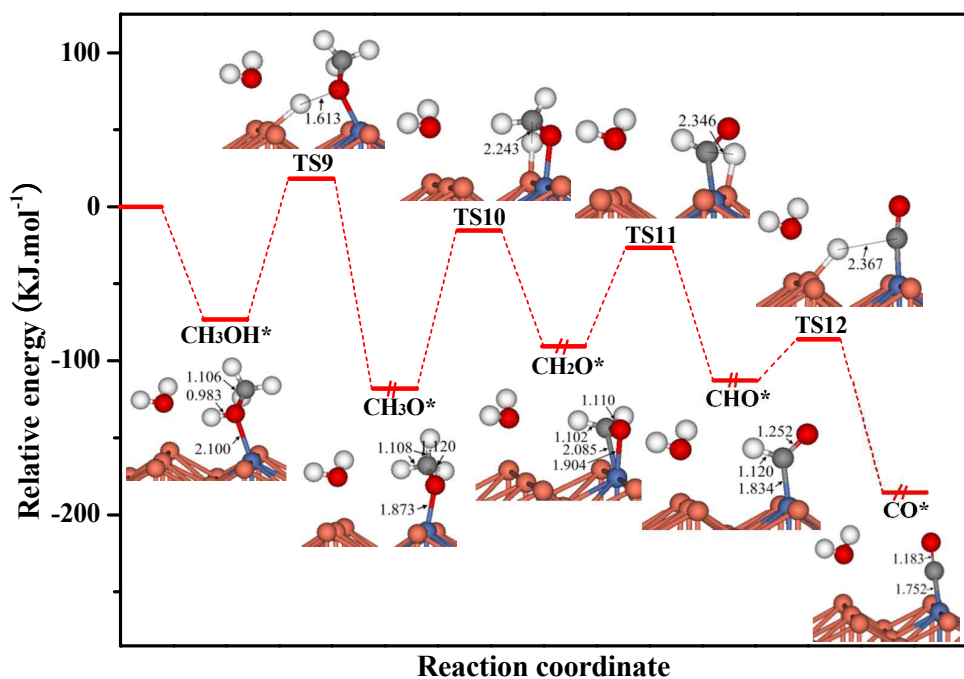


Fig.5 Potential energy profile of the main route for CH₃OH decomposition on the metal Ni doped H₂O/Cu(110) surface.

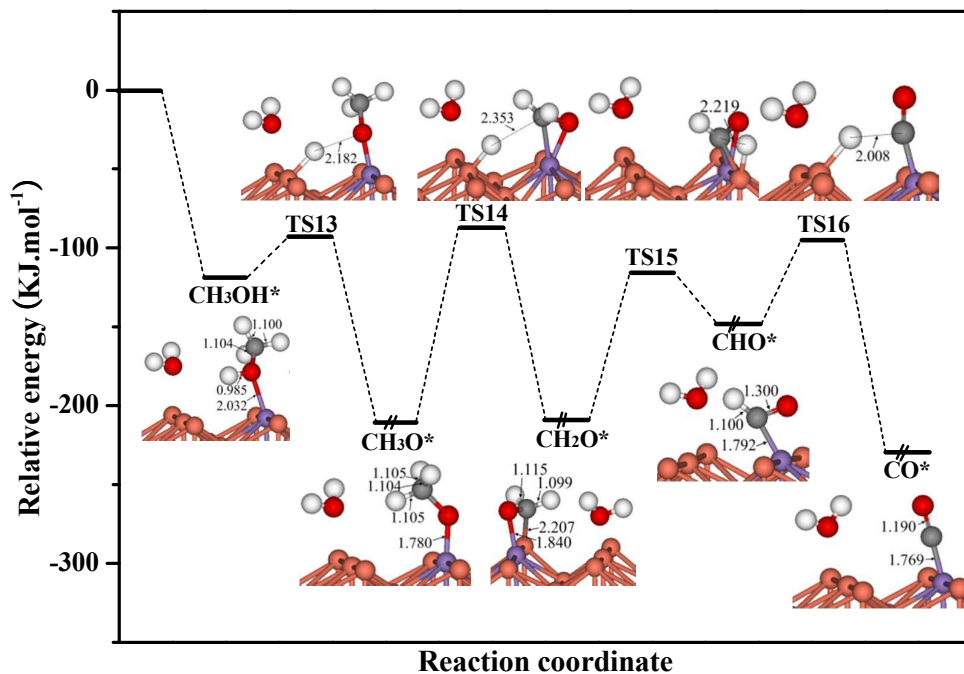


Fig.6 Potential energy profile of the main route for CH_3OH decomposition on the Mn doped $\text{H}_2\text{O}/\text{Cu}(110)$ surface.

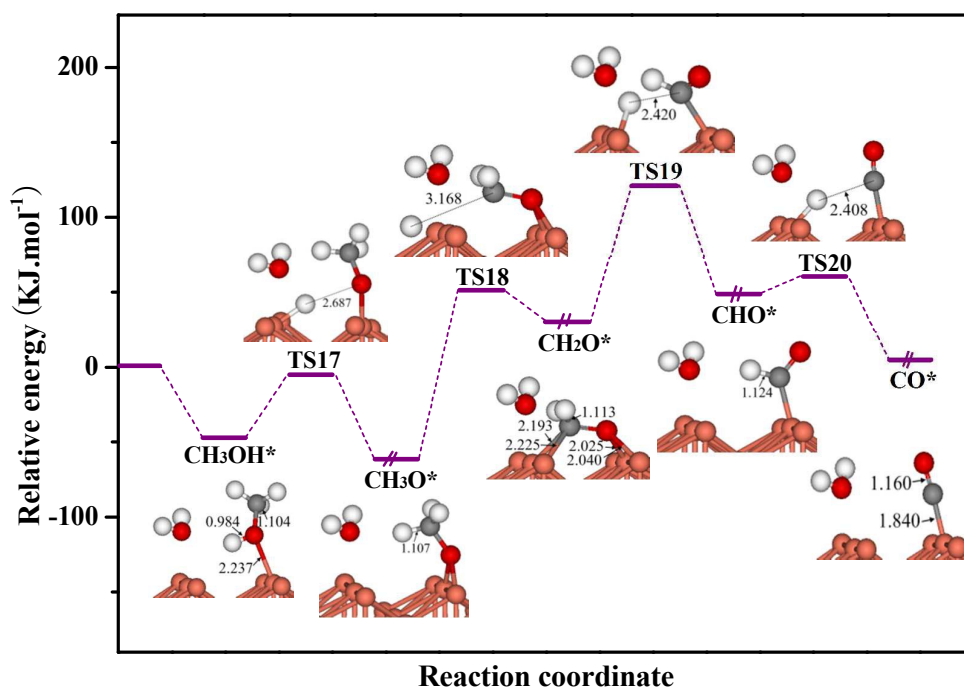


Fig.7 Potential energy profile of the main route for CH_3OH decomposition on the un-doped $\text{H}_2\text{O}/\text{Cu}(110)$ surface.

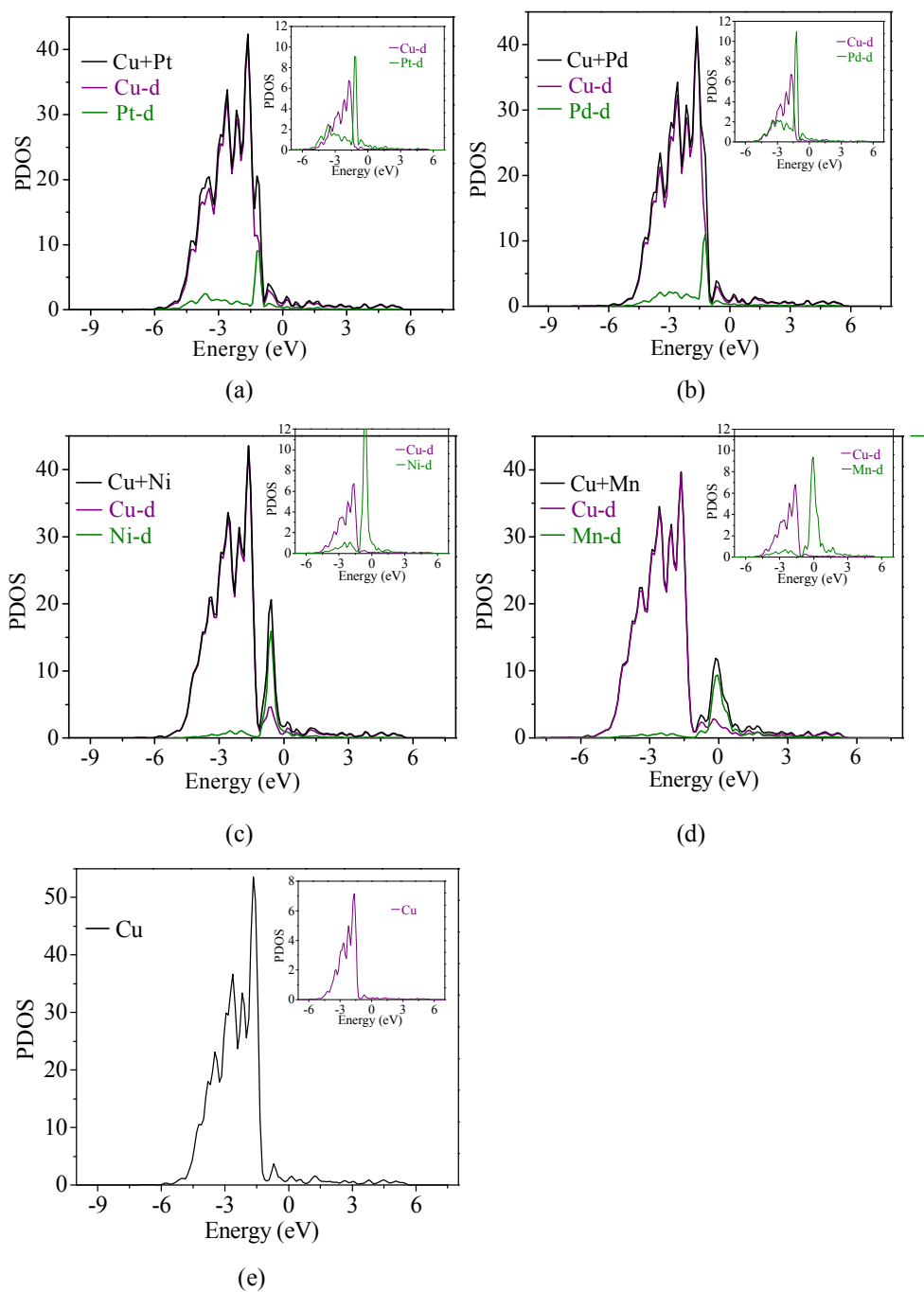


Fig.8. The partial density of states (PDOS) for metal (Pt, Pd, Ni, Mn) doped H₂O/Cu(110) (a, b, c and d) and un-doped H₂O/Cu(110) (e). The insets are the PDOS of the metal dopants and neighboring copper atom.

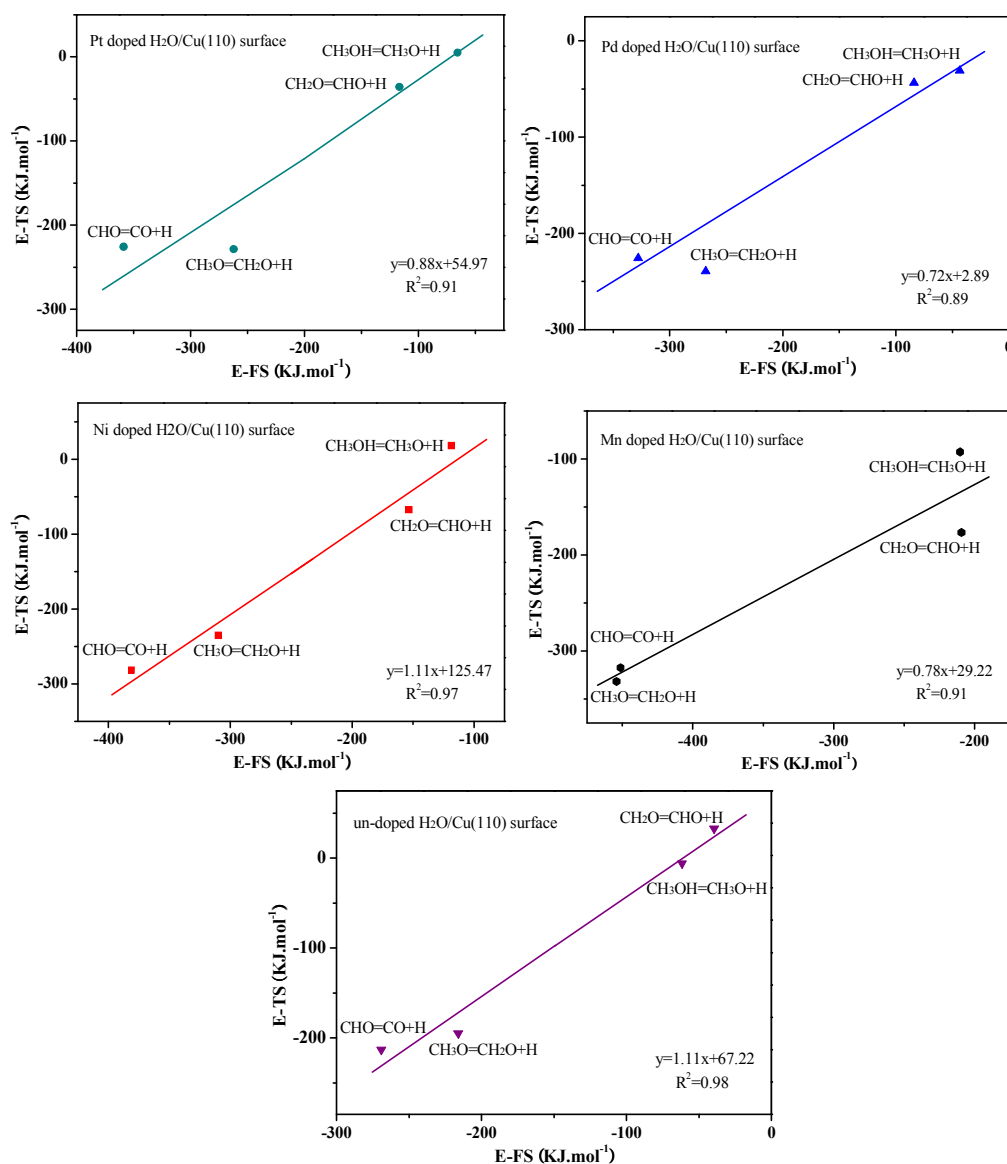


Fig.9. Brønsted-Evans-Polanyi plots of the calculated transition state energy ($E\text{-TS}$) versus final state energy ($E\text{-FS}$) for the main route of CH_3OH decomposition on the metal (Pt, Pd, Ni, Mn) doped and un-doped $\text{H}_2\text{O}/\text{Cu}(110)$ surfaces. The reactant energy in vacuum as a reference to calculate the transition and final state energies of each elementary reaction.

